

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|---------|--------------------------------------|---|------------------|---------|------------------|
| L1 | 2312438 | substrate or wafer | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/11/04 13:21 |
| L2 | 86020 | ion adj (implanting or implantation) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/11/04 13:21 |
| L4 | 21694 | p-well or p adj well | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/11/04 13:48 |
| L5 | 7717 | isolation adj (trench or well) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/11/04 13:21 |
| L6 | 34573 | active adj area | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/11/04 13:24 |
| L7 | 1592 | oxide adj trench | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/11/04 13:24 |
| L9 | 2 | "6355524".pn. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/11/04 13:26 |
| L10 | 34028 | field adj oxide | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/11/04 13:47 |

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|-----|-------|----------------------|---|----|----|------------------|
| L11 | 2158 | trench adj oxide | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/11/04 13:47 |
| L12 | 539 | 10 and 11 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/11/04 13:47 |
| L13 | 239 | 12 and 2 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/11/04 13:47 |
| L14 | 24197 | n-well or n adj well | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/11/04 13:47 |
| L15 | 54 | 13 and 14 and 4 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/11/04 13:49 |
| L17 | 30 | 15 and 6 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/11/04 13:49 |
| L18 | 39 | ("4578128").URPN. | USPAT | OR | ON | 2005/11/04 14:01 |